Heavy Ion Testing at the Galactic Cosmic Ray Energy Peak





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Abstract

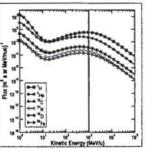
8: MEI Technologies (NASA/GSFC), Greenbelt, MD 20771 USA.

A 1 GeV/u 56Fe ion beam allows for true 90° tilt irradiations of various microelectronic components and reveals relevant upset trends for an abundant element at the galactic cosmic ray (GCR) flux-energy peak.



Space Environment

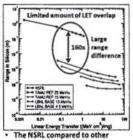
- The galactic cosmic ray (GCR) environment has a fluxenergy peak at ≈1 GeV/u
- · At this level of kinetic energy, LETs > 1 ((MeV-cm2)/mg) are dominated by iron
- · 1 GeV/u 56Fe has an LET of 1.2 ((MeV-cm²)/mg) and a range in silicon of 15 cm



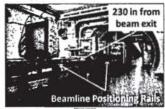
GCR Fluxes for geostationary orbit at solar minimum (CREME96)

Facility

The NASA Space Radiation Effects Laboratory Brookhaven National Laboratory, Long Island, NY USA



- heavy ion facilities Note that the JYFL REF is similar
- to LBNL BASE facility



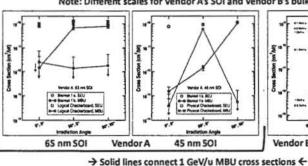
Target Room

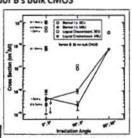
- Facility has rotation and translation stages
- Can stack multiple experiments
- Experiments conducted #230 In from beam

Static Random Access Memories

Note: Different scales for Vendor A's SOI and Vendor B's bulk CMOS

Vendor A's SOI devices have both a data pattern and orientation dependence





Vendor B: 65 nm bulk CMOS

Test setup for normal incidence irradiations

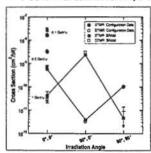
- Taking advantage of 8 in x 8 in beam spot
- Two setups in front and one in back
- · Roughly ± 2% uniformity over this area

Pattern and orientation sensitivities arise from SOI's inter-device isolation and bit cell layout. These features are muted in bulk CMOS due to charge transport.

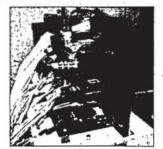
Field Programmable Gate Array

Vendor B's bulk CMOS device only has an orientation dependence

→ Solid lines connect 1 GeV/u configuration and BRAM cross sections ←



- Extreme variation between configuration and BRAM cross section based on orientation
- Suspect physical layout is responsible



- Test setup for 90° tilt, 0° roll irradiations · Taking advantage of 8 in x 8 in beam spot
- All four DUTs are stacked (FPGA on
- Roughly ± 2% uniformity over this area

Conclusions

- · First time the NSRL facility has been used to characterize highly-scaled commercial technologies
- 1 GeV/u ⁵⁶Fe beam allowed for true 90° tilt irradiations
- Extreme upset cross section variation observed as a function of roll angle, data pattern, and storage elements
- Data provides impetus to study these limiting irradiation conditions with radiation transport modeling since studies like these are not feasible on a regular basis

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To be presented by Jonathan A. Pellish at the 2009 RADECS, 14-18 September 2009, Brugge, Belgium